

Correction to “Intrinsic n-type Defect Formation in TiO₂: A Comparison of Rutile and Anatase from GGA+*U* Calculations”

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Equation 6 currently reads as

$$\Delta\mu_{\text{O}}(T, P) = \frac{1}{2} \left\{ [C_P(T - T_0)] - T \left[S_0 + C_P \ln \frac{T}{T_0} + k_B T \ln \frac{P}{P_0} \right] \right\}$$

The correct expression is

$$\Delta\mu_{\text{O}}(T, P) = \frac{1}{2} \left\{ [C_P(T - T_0)] - T \left[S_0 + C_P \ln \frac{T}{T_0} + k_B \ln \frac{P}{P_0} \right] \right\}$$